## What is claimed is:

- 1. An actuator comprising:
- a first region of piezoelectric material;
- a support structure; and

flexures attaching a perimeter of the region to the support structure.

- 2. The actuator of claim 1, further comprising first and second electrodes on opposite faces of the first region.
- 3. The actuator of claim 2, wherein two of the flexures provide respective electrical connections to the first and second electrodes.
  - 4. The actuator of claim 2, further comprising:
  - a second region of piezoelectric material; and
- a third electrode, wherein the second electrode is between the first and second regions, the first electrode is on a side of the first region opposite to the second electrode, and the third electrode is on is on a side of the second region opposite to the second electrode.
- 5. The actuator of claim 1, wherein an electric field applied to the region causes crystal structure change in a plane of the region causing the region to dish, where in dishing provides a stroke of the actuator.
  - 6. The actuator of claim 1, wherein the region is part of a bimorph.
  - 7. The actuator of claim 1, wherein the region is part of a unimorph.
- 8. The actuator of claim 1, wherein a first side of the first region has piezoelectric properties that differ from piezoelectric properties of a second side of the first region.

- 9. The actuator of claim 7, wherein the first side of the region is chemically reduced.
- 10. The actuator of claim 1, wherein the support structure comprises a substrate underlying the region.
- 11. The actuator of claim 10, wherein the substrate comprises electrically conductive traces that the flexures electrically connect to the electrodes.
- 12. The actuator of claim 1, wherein the support structure comprises a frame surrounding the region.
  - 13. An array of actuators having the recited structure of claim 1.
- 14. The array of claim 13, wherein the support structure for each actuator in the array comprises a frame having a hexagonal shape, and the frames are arranged in a hexagonal array.
  - 15. An actuator comprising:
- a region comprising a first layer of piezoelectric material that is between a first electrode and a second electrode; and
- a plurality of flexures attached to a perimeter of the region, wherein the perimeter of the region is unsupported except where the flexures attach to the region.
  - 16. The actuator of claim 15, wherein the plurality of flexures includes: a first flexure providing an electrical connection to the first electrode; and a second flexure providing an electrical connection to the second electrode.
- 17. The actuator of claim 15, wherein the region further comprises a second layer of piezoelectric material that is between the second electrode and a third electrode.

- 18. The actuator of claim 17, wherein the plurality of flexures includes: a first flexure providing an electrical connection to the first electrode; a second flexure providing an electrical connection to the second electrode; and a third electrode providing an electrical connection to the third electrode
- 19. A deformable mirror comprising: an array of piezoelectric actuators fabricated on a substrate; and a mirror membrane attached to the array of piezoelectric actuators.
- 20. The deformable mirror of claim 19, wherein each actuator comprises a bimorph.
- 21. The deformable mirror of claim 19, wherein each actuator comprises a RAINBOW.
- 22. The deformable mirror of claim 19, wherein each actuator comprises: a region of piezoelectric material; a frame surrounding the region; and flexures attaching a perimeter of the region to the frame.
- 23. A process for fabricating an actuator, comprising:

forming a sacrificial layer on a substrate;

forming a trench in the sacrificial layer;

depositing a first conductive layer over the first insulating layer;

patterning the first conductive layer to form a first electrode overlying the sacrificial layer and a first conductive trace extending from the first electrode into the trench;

forming a first disk of piezoelectric material overlying the first electrode;

depositing a second conductive layer overlying the first disk and extending into the trench:

patterning the second conductive layer to form a second electrode overlying the first disk and a second conductive trace extending into the trench; and

etching the sacrificial layer from under the first electrode.

- 24. The process of claim 23, further comprising reducing a top surface of the disk before depositing the second conductive layer.
  - 25. The process of claim 23, further comprising:

forming a second disk of piezoelectric material overlying the second electrode; depositing a third conductive layer overlying the second disk and extending into the trench;

patterning the third conductive layer to form a third electrode on the second disk and a third conductive trace extending into the trench.

- 26. The method of claim 23, further comprising depositing a first protective layer on the sacrificial layer and in the trench, wherein the first protective layer protects the first conductive layer during removal of the sacrificial layer.
  - 27. The process of claim 26, wherein the first protective layer comprises silicon nitride.
- 28. The process of claim 23, wherein the first conductive layer comprises a layer of platinum and a layer of titanium.
  - 29. The process of claim 23, wherein the first disk comprises PZT.
  - 30. A process for fabricating an actuator, comprising:

forming traces on a substrate;

forming a first sacrificial layer overlying the electrical traces;

forming a first conductive plug and a second conductive plug through the first sacrificial layer, wherein the conductive plugs are electrically connected to the traces;

forming a first electrode overlying the first sacrificial layer, wherein the first electrode is

electrically connected to the first conductive plug and electrically isolated from the second conductive plug;

forming a first disk of a piezoelectric material overlying the first electrode;

forming a second electrode on the first disk, wherein the second electrode is electrically connected to the second conductive plug and electrically isolated from the first conductive plug; and

removing the first sacrificial layer from under the first electrode.

## 31. The process of claim 30, further comprising:

forming a third conductive plug through the first sacrificial layer, wherein the third conductive plug is electrically connected to one of the traces;

forming a second disk of a piezoelectric material overlying the second electrode; and forming a third electrode overlying the second disk, wherein the third electrode is electrically connected to the third conductive plug and electrically isolated from the first and second conductive plugs.